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-- In Fig. 16, as well as various of the following figures, reference character 2c denotes the side wall of vacuum chamber 2. --

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-- Fig. 19 shows an eleventh embodiment of the invention. The basic apparatus construction of the present embodiment is identical to that of the eighth embodiment, but what is different from the other embodiments is that magnetic

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Assistant

field generating means 16 is disposed outside the vacuum chamber 1. In Fig. 19, as well as in Fig. 20, reference character 11 is a connector for the interconnecting cable for the RF power supply. The plasma density distribution just above the substrate in the presence of the magnetic field is illustrated in Fig. 25. From the graph showing the plasma density distribution, it is found that the plasma density is higher in the periphery as the magnetic field is increased. Thus, the magnetic field generating means acts as an auxiliary one capable of controlling the distribution.--.